

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: GREGORY J. WILSON ET AL.

APPLICATION No.: 10/817,659

FILED: OCTOBER 20, 2004

FOR: **TUNING ELECTRODES USED IN A REACTOR
FOR ELECTROCHEMICALLY PROCESSING A
MICROELECTRONIC WORKPIECE**

EXAMINER: NICHOLAS A. SMITH

ART UNIT: 1795

CONF. NO: 3413

STATEMENT OF RELATED APPLICATIONS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant calls the Examiner's attention to the following related applications:

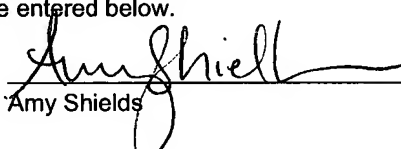
Reference No.	Type	Status	Application No.	Filing Date
63857.8157.US01	CIP	Granted 7,020,537	09/849,505	04-May-2001
63857.8157.US10	CON	Published	11/097,068	31-Mar-2005
63857.8157.US11	CON	Published	11/392,477	28-Mar-2006
63857.8157.US12	DIV	Published	11/639,733	14-Dec-2006
63857.8157.US13	CON	Published	11/739,553	24-Apr-2007
63857.8157.US02	CIP	Granted 7,189,318	09/866,391	24-May-2001
63857.8157.US03	CIP	Granted 7,160,421	09/866,463	24-May-2001
63857.8157.US05	DIV	Published	10/970,809	02-Apr-2004
63857.8157.US06	CON	Published	11/038,455	18-Jan-2005
63857.8157.US07	CON	Published	11/097,508	31-Mar-2005
63857.8157.US08	CON	Published	11/097,671 abandoned	31-Mar-2005
63857.8157.US09	CON	Published	11/096,972	31-Mar-2005

Certificate of Electronic Filing

I hereby certify that this paper (along with any referred to as being attached or enclosed) is being electronically filed with the U.S. Patent and Trademark Office on the date entered below.

August 15, 2008

Date of Electronic Submission


Amy Shields

In a 12/20/2007 Office Action in 11/097,671 (now abandoned), claims were rejected over Poris, USP 5,256,274, in view of Van Raalte, USP 3,880,725, and further in view of Lowenheim text *Electroplating* and the Alkrie article *Transient Behavior During Electrodeposition on to a Metal Strip of High Ohmic Resistance*, Ameen et al., USP 5,685,970 and Ohmure et al., USP 4,401,521, and additionally in view of the Lanzi et al. article, *Terminal Effect at a Resistive Electrode Under Tafel Kinetics*. Claims were also rejected for double patenting over 11/097,068. Reid et al., USP 6,074,544, was made of record with citation to Applicant's 09/880,715 attempting to provoke an interference with Reid et al.

In a 07/28/2008 Office Action in 11/097,068, very similar rejections were made with Poris as the principal reference, but with Wang, USP 6,391,166, also added to the combination of references. Claims in 11/097,068 were also rejected in the 07/28/2008 Office Action over the combination of Poris in view of Iacopani, USP 6,110,345, Lowenheim, Alkrie, Ameen et al., Ohmure et al. and Lanzi et al, and over this combination further including Van Raalte et al. or Wang. Claims in 11/097,068 were also rejected in the 07/28/2008 Office Action over the combination of Reid et al., USP 6,074,544, in view Van Raalte et al. or Wang, and in view of Reid et al. and Iacopani, alone, and in further combination with Van Raalte et al. or Wang.

In a 12/27/2007 Office Action in 11/038,455, claims were rejected over Teichiku KK, (Inagaki) JP 59-150094 and Asada, USP 5,684,713.

Dated: August 1, 2008

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